

LIST OF REFERENCES CITED BY APPLICANT

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ATTY. DOCKET NO.

10177-142-999

APPLICATION NO.

09/891,715

APPLICANT

Mueller

FILING DATE

June 26, 2001

ART UNIT

3763

U.S. PATENT DOCUMENTS

*Examiner Initials	Document Number	Date mm/dd/yy	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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FOREIGN PATENT DOCUMENTS

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NY1-4041376v1
008563 - 999140**EXAMINER****DATE CONSIDERED**

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NON PATENT LITERATURE DOCUMENTS

*Examiner Initials		Include name of the author (in CAPITAL LETTERS), (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T
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NY1-4041376v1
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/Theodore Stigell/ (10/12/2008)

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